Copper(II) Chloride Dihydrate: A Catalytic Agent for the Deprotection of Tetrahydropyranyl Ethers (THP Ethers) and 1-Ethoxyethyl Ethers (EE Ethers)† Jianbo Wang,* Chao Zhang, Zhaohui Qu, Yihua Hou, Bei Chen and Peng Wu

Department of Chemistry, Peking University, Beijing 100871, P.R. China

Tetrahydropyranyl ethers (THP groups) and 1-ethoxyethyl ethers (EE groups) are removed upon refluxing in 95% EtOH or Me_2CO-H_2O (95:5) in the presence of a catalytic amount of copper(1) chloride dihydrate (2–5 mol%).

Protecting groups play an important role in organic synthesis. Among the various methods for protecting hydroxy groups, the formation of tetrahydropyranyl ethers (THP groups) is one of the most widely used methods because of their easy formation and inertness to various reaction conditions. The deprotection of THP groups is usually under dilute aqueous acidic condition, such as acetic acid. p-toluenesulfonic acid or boric acid, etc.¹ In recent years, a number of different methods have been reported for the deprotection of THP groups.² Nevertheless, it is still desirable to develop alternative and milder conditions to remove protecting groups. We report here a simple and efficient process for the removal of THP groups and related 1-ethoxyethyl ethers (EE groups),¹ in which only a catalytic amount of copper(II) chloride dihydrate is required. In addition, we also investigated the ability of $CuCl_2 \cdot 2H_2O$ to cleave the structurally related cyclic dioxolane derivatives, which are common protective groups for carbonyl groups.¹

A number of THP and EE ethers with different structures were prepared according to standard procedures.³ The THP ethers were subjected to reflux in 95% EtOH containing 5 mol% of copper(II) chloride dihydrate (Scheme 1). Under such conditions all the THP groups investigated in our study were cleanly and completely removed within 2–3 h, and the corresponding alcohols were isolated in good yields. Some acid sensitive functional groups, such as epoxide and tertiary hydroxy groups, were found to tolerate this condition (Table 1, entries 10 and 11).⁴ EE groups can be similarly

Table 1 Deprotection of THP and EE ethers with a catalytic amount of $CuCl_2 \cdot H_2O$

Entry	Compound	Reaction time ^a /h	Isolated yield (%)	Entry	Compound	Reaction time ^a /h	Isolated yield (%)
1	Me(CH ₂) ₂₁ OTHP	3.0	91		OAc		
2	OTHP	2.0	89	10		1.5	78
3	EtO ₂ C-CTHP	3.0	92	·			
4		2.0	98	11		1.5	91
				12	Me CO2Et OTHP	2.0	91
				13	Me(CH ₂) ₉ OEE	1.0	92
5		2.5	90 ^b	14	OEE	1.0	91
6	OTHP ^c	2.0	92	15	CH2CH2OEE	1.0	92
7	CH ₂ CH ₂ OTHP	2.0	93		C ₈ H ₁₇		
8	OTHP	3.0	93	16	EEO	1.0	96
9	ОНСОТНР	2.0	92	17 /	OEE°	1.0	95

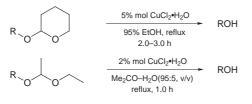
^{*a*} Reaction conditions: for THP ethers, 5 mol% of CuCl₂ · H₂O was refluxed with the protected compound in 95% EtOH. For EE ethers, 2% mol of CuCl₂ · H₂O was refluxed with the protected compound in Me₂CO-H₂O (95:5, v/v). ^{*b*} Both THP and dioxolane groups were removed, and the isolated product was epiandrosterone. ^{*c*} The reaction was run under an N₂ atomsphere.

removed under the same condition. As expected, we found it was easier to remove EE groups and the solvent could be replaced by Me_2CO-H_2O (95:5 v/v). The removal of THP groups with Me_2CO-H_2O (95:5) as solvent is however, slow. For example, refluxing $Me[CH_2]_{21}OTHP$ with 5% mol

J. Chem. Research (S), 1999, 294–295[†]

^{*} To receive any correspondence (*e-mail*: wangjb@pku.edu.cu). † This is a **Short Paper** as defined in the Instructions for Authors, Section 5.0 [see *J. Chem. Research* (*S*), 1999, Issue 1]; there is therefore no corresponding material in *J. Chem. Research* (*M*).

 $CuCl_2 \cdot H_2O$ in Me_2CO-H_2O (95:5 v/v) for 6 h gave the parent alcohol in only 25% isolated yield.



Scheme 1

In order to gain some insight into the mechanism of this novel deprotection process, we investigated the reaction with anhydrous CuCl₂ in anhydrous EtOH. We found that both THP and EE groups could be removed as efficiently as when using CuCl₂·2H₂O in H₂O-containing EtOH. Therefore, H₂O is not indispensable for these reactions. However, refluxing of EE protected compound with anhydrous CuCl₂ in anhydrous acetone led to decomposition to several unidentified products. Additionally THF-H₂O (95:5 v/v) was an unsuitable solvent for deprotection and led to no reaction after refluxing for several hours. We also tested CuSO₄·5H₂O and Cu(acac)₂ and found them to be ineffective in the deprotection of THP or EE groups under the same conditions.

Since an aqueous solution of CuCl₂ is acidic (pH 3.6 in 0.2 M aqueous solution), it is most possible that these deprotection reactions are simply acid-catalyzed hydrolysis of acetals. However, considering the catalytic amount of CuCl₂ in the reaction system, it is also likely that metal complexation is involved in the reaction so as to facilitate. Sen *et al.* recently reported that FeCl₃ · 6H₂O could remove THP protecting groups.⁵ It seems likely that these processes have some common feature in the reaction pathway. However, the detailed mechanism for CuCl₂-promoted deprotection is still unclear.

In Table 1 (entry 5), both THP and dioxolane groups in the 3β -OH and 17-oxo-protected epiandrosterone were found to be removed under the CuCl₂-promoted deprotection conditions. This suggests that dioxolane groups in general might be also removed under the same reaction conditions. We then investigated the ability of CuCl2·2H2O to cleave cyclic dioxolane derivatives. Thus, ketals and acetals were prepared according to standard procedures,1 and the deprotection was conducted under the same conditions as for the THP ethers and results are summarized in Table 2. Although the deprotection indeed worked in most of cases, the reaction generally takes longer than for corresponding deprotection of THP or EE groups. In several cases, the reaction did not proceed to completion (Table 2, entries 3, 4 and 5). In one case, the acetal group was not cleaved and the starting material was recovered unchanged (entry 6).

In conclusion, we have discovered an efficient method for the deprotection of THP and EE groups. The reaction is remarkably simple and requires only a catalytic amount of inexpensive and readily available $copper(\pi)$ chloride dihydrate.

Experimental

CuCl₂·2H₂O was obtained from Beijing Chemical Reagent Co., China and anhydrous CuCl₂ was purchased from Aldrich. All solvents were distilled prior to use. 100–200 Mesh silica gel (Qingdao, China) was employed for column chromatography purification. THP ethers, EE ethers and dioxolane derivatives were prepared by standard procedures and characterized by ¹H (200 MHz) and ¹³C NMR (50 MHz).

cedures and characterized by ¹H (200 MHz) and ¹³C NMR (50 MHz). General Procedure for Deprotection with CuCl₂·H₂O.—The protected compound (1 mmol) was dissolved in 95% EtOH (10 mL) or Me₂CO-H₂O (95:5 v/v; 10 mL). To the solution was added

Table 2	Deprotection	of	cyclic	dioxolanes	with	а	catalytic
amount of	$CuCl_2 \cdot H_2O^a$						

Entry	Compound	Reaction time ^a /h	Isolated yield (%)
1	Å,	3.0	90 ^b
2	OAc H	2.5	94 ^b
3	+	5.5	95(5) ^c
4	Me(CH ₂) ₂₀ C H O	7.5	47(53) ^c
5		4.5	90(10) ^c
6	0 ₂ N-	3.5	0(100) ^c

^{*a*} Reaction conditions: CuCl₂·H₂O was refluxed with the protected compound in 95% EtOH. ^{*b*} 5% mol CuCl₂·H₂O was used. The deprotections were complete, and the yields refer to isolated yield. ^{*c*} 10% mol CuCl₂·H₂O was used. The reactions were not complete. The relative yields were estimated by ¹H NMR and the numbers in parentheses refer to unreacted materials.

CuCl₂·H₂O (0.05 or 0.01 mmol and the homogenous solution was heated under gentle reflux until completion of the reaction (monitored by TLC). After cooling, the solvent was removed by evaporation. Diethyl ether (30 mL) was added to the residue, and the mixture was washed with H₂O and saturated aqueaus NaCl. The ethereal solution was dried over anhydrous MgSO₄. Removal of the drying agent and the solvent gave a crude product, which was purified by column chromatography with silica gel. The pure parent compound was identified by comparison with an authentic sample (TLC, ¹H NMR, ¹³C NMR).

Financial support by the State Education Commission of China (Excellent Young Teacher's Foundation to J. W), and NSFC (Grant No. 29702002) is gratefully acknowledged.

Received, 8th January 1998; Accepted, 20th January 1999 Paper E/9/00262F

Reference

- 1 T. W. Greene and P. G. M. Wutz, *Protective Groups in Organic Synthesis*, John Wiley and Sons, Inc., New York, 1991.
- (a) I. Mohammadpoor-Baltork and S. Pouranshirvani, Synthesis, 1997, 756; (b) A. Srikrishina, J. A. Sattigeri, R. Viswajananii and C. V. Yelamaggad, J. Org. Chem., 1995, 60, 2260; (c) K. P. Nambiar and A. Mitra, Tetrahedron Lett., 1994, 35, 3033; (d) G. M. Caballero and E. G. Gros, Synth. Commun., 1995, 25, 395; (e) A. Wagner, M. P. Heitz and G. Mioskowski, J. Chem. Soc., Chem. Commun., 1989, 1619; (f) S. Kim and J. H. Park, Tetrahedron Lett., 1987, 28, 439; (g) J. Otera and H. Nozaki, Tetrahedron Lett., 1986, 27, 5743; (h) Y. Ogawa and M. Shibasaki, Tetrahedron Lett., 1984, 25, 663.
- 3 M. Miyashita, A. Yoshikoshi and P. A. Grieco, J. Org. Chem., 1977, 42, 3772.
- 4 However, we found that *tert*-butyldimethylsilyl(TBDMS) ethers were also hydrolyzed under these conditions.
- 5 S. G. Sen, S. L. Roach, J. K. Boggs, G. J. Ewing and J. Magrath, *J. Org. Chem.*, 1997, **62**, 6684.